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## Instability of an electron-plasma shear layer in a strain flow.<sup>1</sup>

J. R. DANIELSON<sup>2</sup>, University of California San Diego

The  $E \times B$  shear instability of a two-dimensional (2D) filament (i.e., a thin, rectangular strip) of a magnetized pure electron plasma is studied in the presence of an externally imposed strain flow.<sup>3</sup> Experiments are conducted using a specially designed Penning-Malmberg trap in which such flows can be imposed in 2D by biasing segmented electrodes surrounding the plasma. Electron density, which is the analog of fluid vorticity, is measured directly with a CCD camera. The situation studied corresponds to the Rayleigh instability of a finite-width shear layer in a 2D incompressible fluid. Theory predicts that neutrally stable traveling waves on opposite surfaces of the filament will phase lock and go unstable. The experimentally observed phase locking and the time-evolution of the wavenumber spectrum are in quantitative agreement with a linear model<sup>4</sup> that extends Rayleigh's work to account for the imposed strain flow. For weak strain, the system maintains a phase relationship that corresponds to an instantaneous (though evolving) Rayleigh eigenmode. A nonlinear regime is observed at later times that includes wave breaking, vortex formation, a vortex-pairing instability, and vorticity transport perpendicular to the filament. This evolution is suppressed, but not quenched as the strain rate is increased. Remaining open questions will be discussed.

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<sup>3</sup>N. C. Hurst, J. R. Danielson, D. H. E. Dubin, and C. M. Surko, *Phys. Plasmas* 27, 042101 (2020).

<sup>4</sup>D. G. Dritschel, P. H. Haynes, M. N. Juckes, and T. G. Shepherd, *J. Fluid Mech.* **230**, 647 (1991).